L	Hits	Search Text	DB	Time stamp
Number			55	Time Scamp
-	220	313/\$.ccls. and organic and sulfur	USPAT;	2003/09/29
			US-PGPUB; EPO; JPO	14:23
-		313/326.ccls. and (carbon and sulfur)	USPAT;	2002/06/14
		(US-PGPUB;	14:16
			EPO; JPO	
-	767	313/310.ccls.	USPAT;	2002/06/14
			US-PGPUB; EPO; JPO	14:16
-	127	252/519.4.ccls.	USPAT;	2002/06/14
			US-PGPUB;	14:18
_	828	(carbon same sulfur) and ("image forming"	EPO; JPO USPAT;	2022/06/14
	020	or "electron emitting" or display) and	US-PGPUB;	2002/06/14 14:20
		film and electrode	EPO; JPO	11.20
-	844	313/495.ccls.	USPAT;	2002/06/14
			US-PGPUB;	14:20
_	11	252/519.4.ccls. and "thin film"	EPO; JPO USPAT;	2002/06/14
		The state of the s	US-PGPUB;	14:20
		l	EPO; JPO	
-	5	(313/306.ccls. or 313/308.ccls.) and	USPAT;	2002/06/14
	1	sulfur	US-PGPUB; EPO; JPO	14:20
ĺ –	18	313/495.ccls. and (carbon and sulfur)	USPAT;	2002/06/14
		, , , , , , , , , , , , , , , , , , , ,	US-PGPUB;	14:20
	,	050/510 14 3 1 1 3 6	EPO; JPO	
_	7	252/519.14.ccls. and carbon and sulfur	USPAT; US-PGPUB;	2002/06/14
			EPO; JPO	14:20
-	17	252/519.4.ccls. and carbon and sulfur	USPAT;	2002/06/14
			US-PGPUB;	14:20
_	148	313/\$.ccls. and (carbon or organic) and	EPO; JPO	2000/06/24
	140	sulfur and (conductor or semiconductor)	USPAT; US-PGPUB;	2002/06/14
		and substrate	EPO; JPO	11.20
-	2156	(Carbon and Sulfur) and (film or	USPAT;	2002/12/01
		deposition) and semiconductor not photographic not ink not batteries not	US-PGPUB; EPO; JPO	22:35
		battery	EPO; JPO	
-	4	"6267636"	USPAT;	2002/12/01
	i l		US-PGPUB;	22:31
_	109	313/\$.ccls. and (carbon or organic) same	EPO; JPO	2002/12/01
	109	sulfur and (conductor or semiconductor)	USPAT; US-PGPUB;	2002/12/01
		and substrate	EPO; JPO	
-	239	(Carbon same Sulfur) same (film or	USPAT;	2002/12/01
		deposition) and semiconductor not photographic not ink not batteries not	US-PGPUB; EPO; JPO	22:43
	,	battery	EFO, UPO	
-	187	(Carbon same Sulfur) same (film or	USPAT;	2002/12/01
	i	deposition) and semiconductor not	US-PGPUB;	22:43
		photographic not ink not batteries not battery not tetrafluoride	EPO; JPO	
-	7	(Carbon same Sulfur) same (film or	USPAT;	2002/12/01
	.	deposition) and semiconductor not	US-PGPUB;	22:51
		photographic not ink not batteries not	EPO; JPO	
_	33	battery not tetrafluoride and carbon.ti. (Carbon same Sulfur) same (film or	Henam.	2002/12/02
	33	deposition) not photographic not ink not	USPAT; US-PGPUB;	2002/12/02
j		batteries not battery not tetrafluoride	EPO; JPO	
		and "carbon film"		
-	40	(Carbon same Sulfur) same (film or	USPAT;	2002/12/02
	ļ	deposition or layer) not photographic not ink not batteries not battery not	US-PGPUB; EPO; JPO	02:09
		tetrafluoride and "carbon film"		

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- 16 313/311.ccls. and (carbon and sulfur)	-	4	313/346R.ccls, and (carbon and sulfur)		
- 16 313/311.ccls. and (carbon and sulfur) USPAT: US-PGPUB; 14:24 EP0; JPO USPAT: 2003/09/29 US-PGPUB; EP0; JPO USPAT: 2003/09/29					14:24
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- 39 252/519.4.ccls. and carbon USPAT: (Carbon same Sulfur) same (film or deposition) not photographic not ink not batteries not battery not tetrafluoride and (carbon same Sulfur) same (film or deposition) and semiconductor not photographic not ink not batteries not battery not tetrafluoride and "carbon film" 2003/09/29 USPAT: US-PGPUB: EPO; JPO USPAT: USPAT: USPAT: USPAT: USPAT: USPAT: USPAT: USPAT: USPAT: Deposition) and semiconductor not photographic not ink not batteries not battery not tetrafluoride and "carbon film"				US-PGPUB;	
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battery not tetrafluoride and "carbon film"					14:25
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	_	7		USPAT;	2003/09/29
US-PGPUB; 14:25		Ĺ			
EPO; JPO					